Notice of References Cited

Application/Control No. 09/659,779	Reexaminati	Applicant(s)/Patent Under Reexamination OGURO, TOSHIHARU		
Examiner	Art Unit			
Kim T. Huynh	2112	Page 1 of 1		

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
X	Α	US-6,434,744	08-2002	Chamberlain et al.	717/168
æ	В	US-6,438,749	08-2002	Chamberlain, Benjamin C.	717/174
X	С	US-6,141,705	10-2000	Anand et al.	710/15
¥	D	US-6,205,498	03-2001	Habusha et al.	710/29
X	E	US-6,067,628	05-2000	Krithivas et al.	713/340
#	F	US-6,260,091	07-2001	Jayakumar et al.	710/113
x	O	US-6,009,490	12-1999	Fukui et al.	710/113
R	Η	US-5,822,520	10-1998	Parker, Steven D.	709/230
X	ı	US-6,771,664	08-2004	Garney et al.	370/474
	J	US-			
	К	US-			
	L	US-			
	М	US-			

FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N.					
	0					
	Р					
	Q					100
	R					
	S					
	Т				** *** *** *** **** **** **** **** **** ****	-

NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	
	٧	
	W	
	х	

*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).) Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.